| | Application No. | Applicant(s) | |
|--|---|---|------------------|
| Notice of Allowability | 10/765,910 | MANGER, DIRK | |
| | Examiner | Art Unit | |
| | Chuong A. Luu | 2818 | |
| The MAILING DATE of this communication apperature All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RI of the Office or upon petition by the applicant. See 37 CFR 1.313 | (OR REMAINS) CLOSED in or other appropriate communication is supplication is supplication. | this application. If not included nication will be mailed in due cou | rse. THIS |
| 1. This communication is responsive to <u>1/3/2006</u> . | | | |
| 2. ☑ The allowed claim(s) is/are <u>1-18</u> . | | | |
| Acknowledgment is made of a claim for foreign priority un a) ☐ All b) ☐ Some* c) ☐ None of the: | der 35 U.S.C. § 119(a)-(d) o | r (f). | |
| Certified copies of the priority documents have | been received. | | |
| 2. Certified copies of the priority documents have | been received in Application | n No | |
| 3. Copies of the certified copies of the priority doc | cuments have been received | in this national stage application | from the |
| International Bureau (PCT Rule 17.2(a)). | | | |
| * Certified copies not received: | | | |
| Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONM THIS THREE-MONTH PERIOD IS NOT EXTENDABLE. | | a reply complying with the require | ements |
| 4. A SUBSTITUTE OATH OR DECLARATION must be subminification (PTO-152) which give | | | CE OF |
| 5. CORRECTED DRAWINGS (as "replacement sheets") mus | t be submitted. | | |
| (a) ☐ including changes required by the Notice of Draftspers | | (PTO-948) attached | |
| 1) ☐ hereto or 2) ☐ to Paper No./Mail Date | | | |
| (b) ☐ including changes required by the attached Examiner's Paper No./Mail Date | s Amendment / Comment or | n the Office action of | |
| Identifying indicia such as the application number (see 37 CFR 1. each sheet. Replacement sheet(s) should be labeled as such in t | | | :k) of |
| DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT I | sit of BIOLOGICAL MATE FOR THE DEPOSIT OF BIO | RIAL must be submitted. Note LOGICAL MATERIAL. | : the |
| | | | |
| Attachment(s) | C Nation of last | anned Detect Appliestics (DTO 45 | -0) |
| 1. Notice of References Cited (PTO-892) | | ormal Patent Application (PTO-15 |)2) |
| Notice of Draftperson's Patent Drawing Review (PTO-948) Information Disclosure Statements (PTO-1449 or PTO/SB/0 | | Mail Date Nail Date Namendment/Comment | |
| Paper No./Mail Date 4. Examiner's Comment Regarding Requirement for Deposit | | Statement of Reasons for Allowar | nce |
| of Biological Material | | | NG |
| | 9. Other | • | |
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DETAILED ACTION

Allowable Subject Matter

Claims 1-18 are allowed.

The following is an examiner's statement of reasons for allowance: The following is an examiner's statement of reasons for allowance: The examiner has reviewed the prior art in light of applicant's claimed invention and finds that the combined claims define over the prior art. The cited prior art does not disclose or suggest a semiconductor device inter alia the limitations "....providing at least one original fin made of a single crystalline semiconductor material on a substrate by means of a first lithography step; then providing a gate dielectric layer over longitudinal sides of the at least one original fin, then providing a gate electrode layer made of a conductive gate electrode material over the gate dielectric layer; forming contact trenches that pattern the at least one original fin in a longitudinal direction by mean of a second lithography step, wherein at least one transistor fin with a first head end and a second head end at a distance of a fin length from the first head end emerges from the at least one original fin, and wherein a gate electrode associated with the transistor fin emerges from the gate electrode layer; then processing the gate electrode, wherein the gate electrode recedes from both head ends; forming a source/drain- region in each transistor fin from the respective two head ends respectively..."

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should

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preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Chuong A. Luu whose telephone number is (571) 272-1902. The examiner can normally be reached on M-F (6:15-2:45).

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David C. Nelms can be reached on (571) 272-1787. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pairdirect.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (tollfree).

> Chuong Anh Luu Patent Examiner

February 10, 2006